

Operation	Product group	Organizational set-up prior August 2016			Organizational set-up starting August 2016				
		Adress	Legal Entity	CFS ID	Adress	Legal Entity	CFS ID	CFSI audit date	approved
Goslar	Tantalum metal powder (Capacitor, Sputter Target) Tantalum pentoxide und hydroxide Potassium tantalum fluoride (K2-salt)	Im Schleeke 78-91 38642 Goslar	H.C. Starck GmbH	CID002545	Im Schleeke 78-91 38642 Goslar	H.C. Starck Tantalum and Niobium GmbH	CID002545	Nov 16	Yes
Laufenburg	Tantalum Chloride Syn. Tantalum Ore	Säckinger Straße 51 79725 Laufenburg Ferroweg 1 79725 Laufenburg	Tantalum Chloride: H.C. Starck GmbH Synthetic Tantalum Concentrate: H.C. Starck Smelting GmbH	CID002546 CID002550	Ferroweg 1 79725 Laufenburg	H.C. Starck Smelting GmbH & Co. KG	CID002550	Nov 16	Yes
Mito	Tantalum metal powder (Capacitor, Sputter Target)	No. 9 Industrial Park Hitachi Ohmiya-shi, Ibaraki 319-2134	H.C. Starck Ltd.	CID002549	No. 9 Industrial Park Hitachi Ohmiya-shi, Ibaraki 319-2134	H.C. Starck Ltd.	CID002549	Dec 16	Yes
Map Ta Phut	Tantalum metal powder (Capacitor, Sputter Target) Potassium tantalum fluoride (K2-salt)	5, I-3A Road, Map Ta Phut Industrial Estate Rayong 21150	H.C. Starck Co., Ltd.	CID002544	5, I-3A Road, Map Ta Phut Industrial Estate Rayong 21150	H.C. Starck Co., Ltd.	CID002544	Dec 16	Yes